

Current Status of the SCRIT Electron Scattering Facility

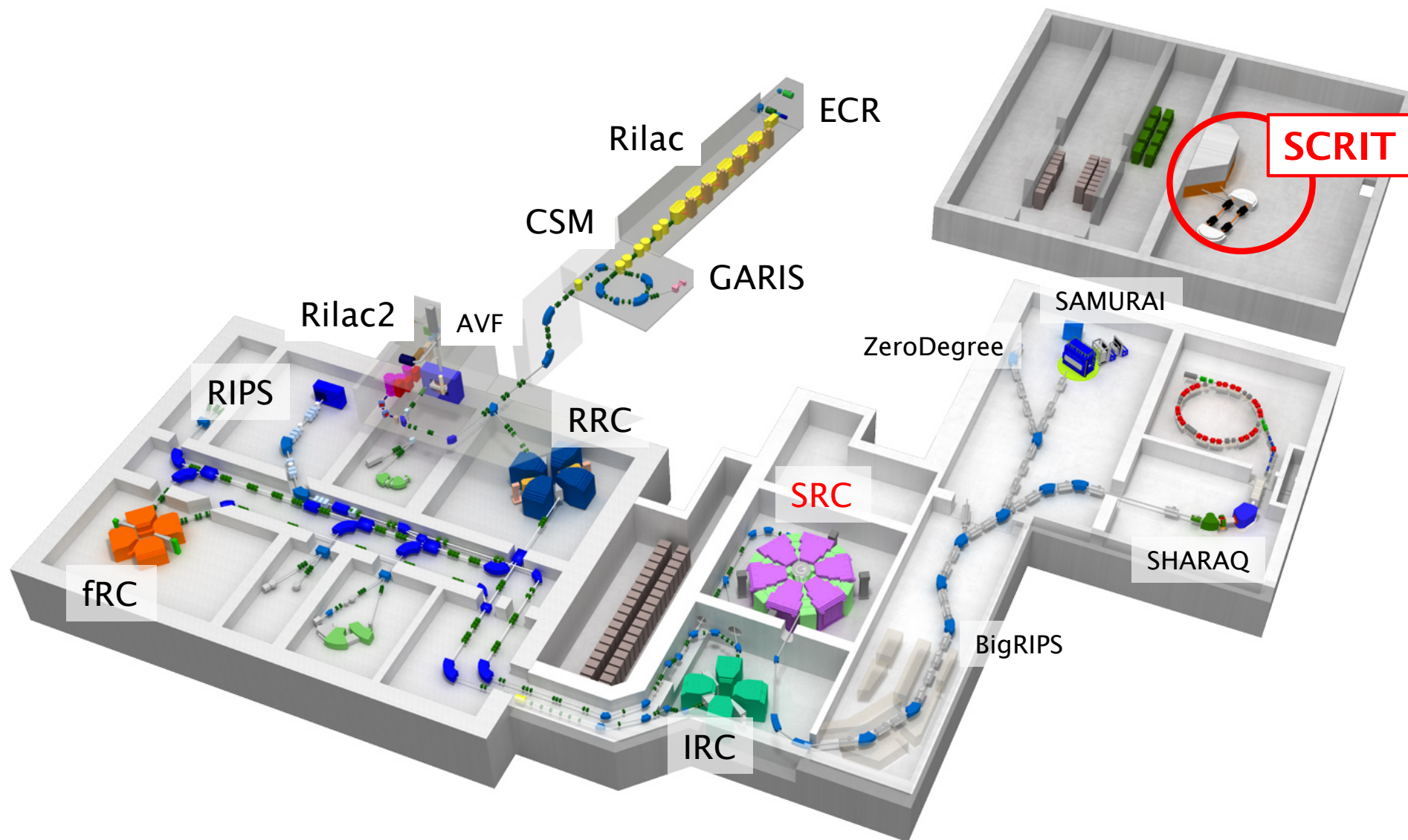
M. Wakasugi and SCRIT collaborations

ECT* Work Shop
Proving Exotic Structure of Short-lived Nuclei by Electron Scattering
(16–20 July. 2018)

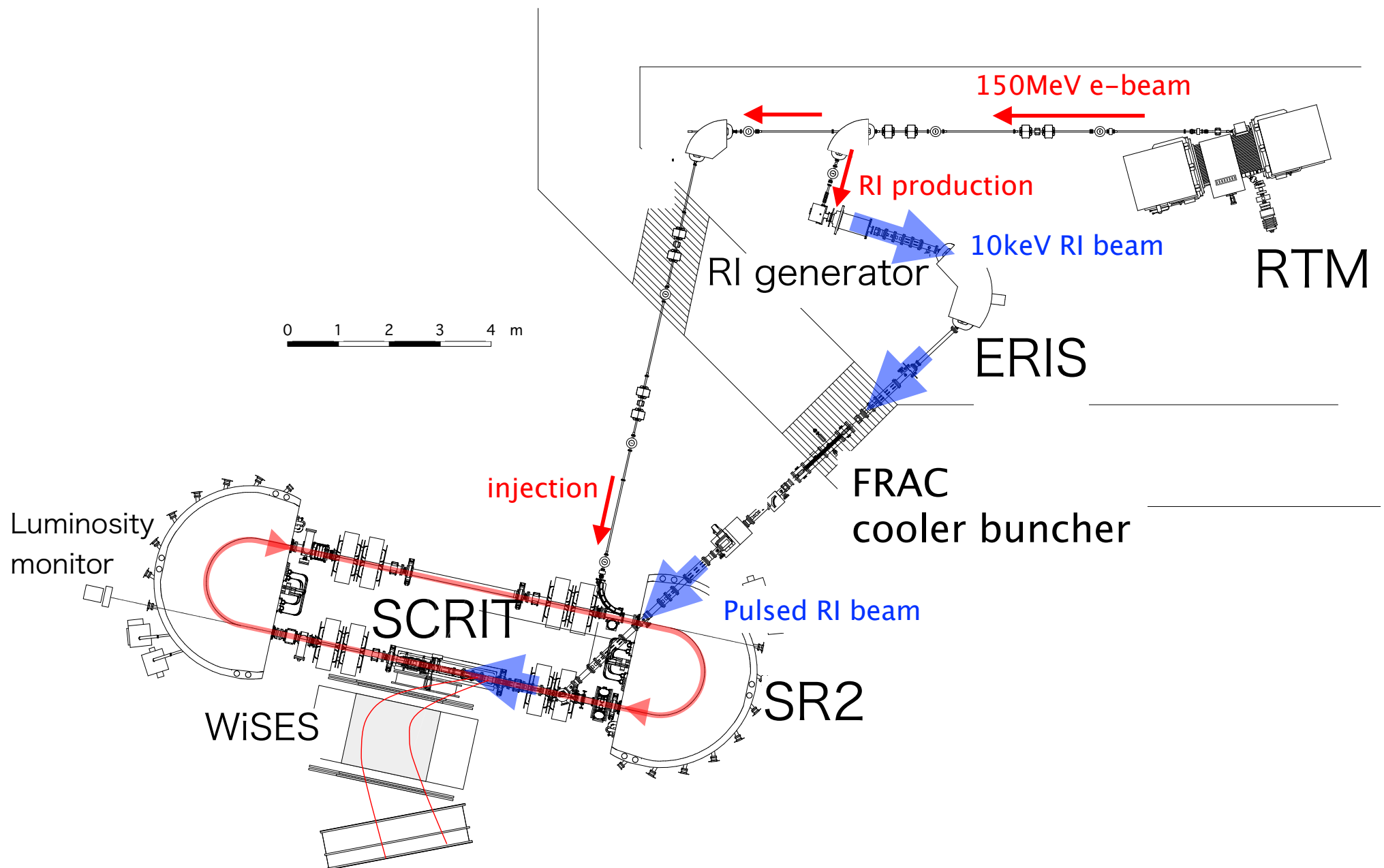
Contents :

- 1. Overview of the facility and the SCRIT system**
- 2. Achieved luminosity and achievable luminosity in SCRIT system**
- 3. Properties of target ions trapped in SCRIT**
- 4. Preparation of target RI ions**
- 5. Summary**

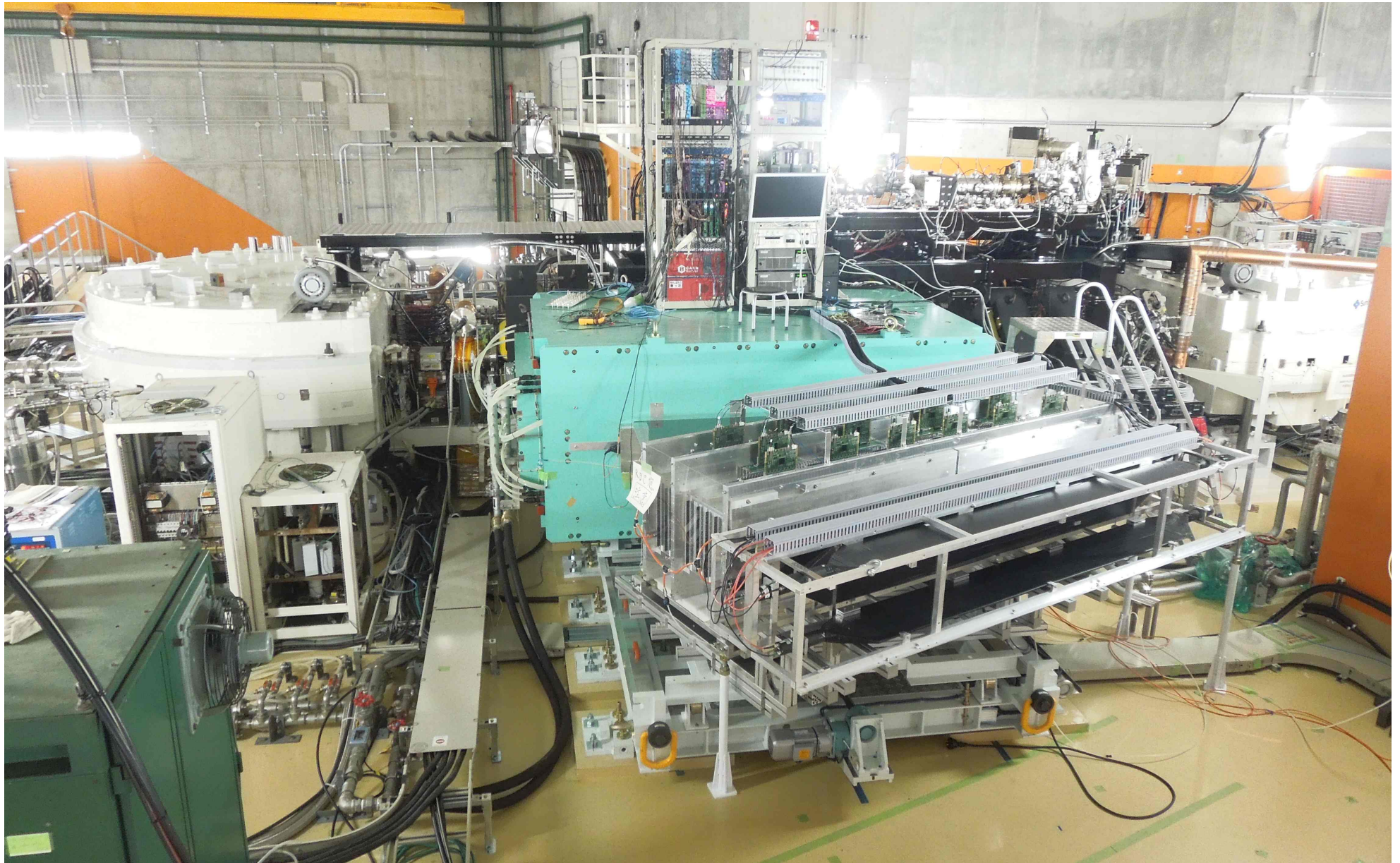
The SCRIT Facility in the RIKEN RI Beam Factory



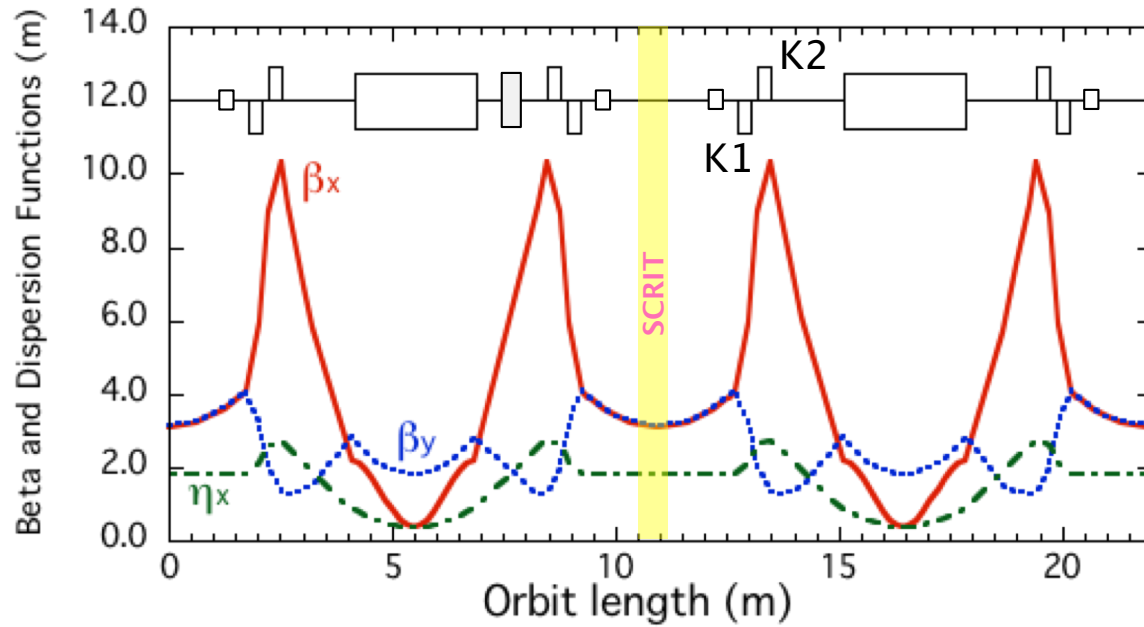
The SCRIT Electron Scattering Facility



The SCRIT Electron Scattering Facility

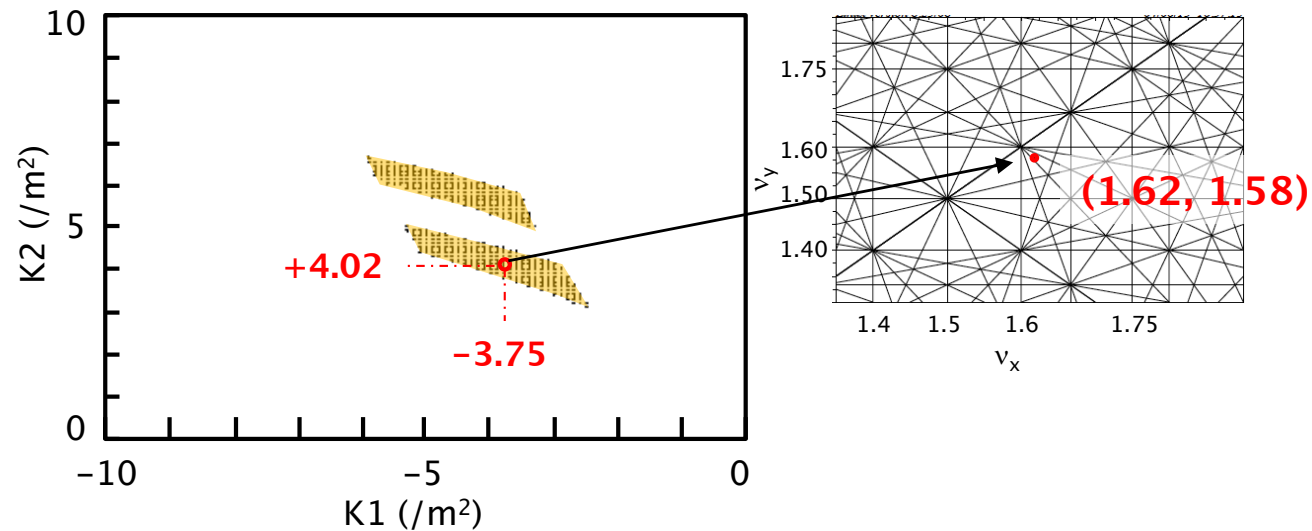


Electron Storage Ring (SR2)



$C = 21.95 \text{ m}$
 $E_e = 100 \sim 700 \text{ MeV}$
 $I_e \leq 300 \text{ mA}$
 $RF = 191.244 \text{ MHz}$
 $h = 14$

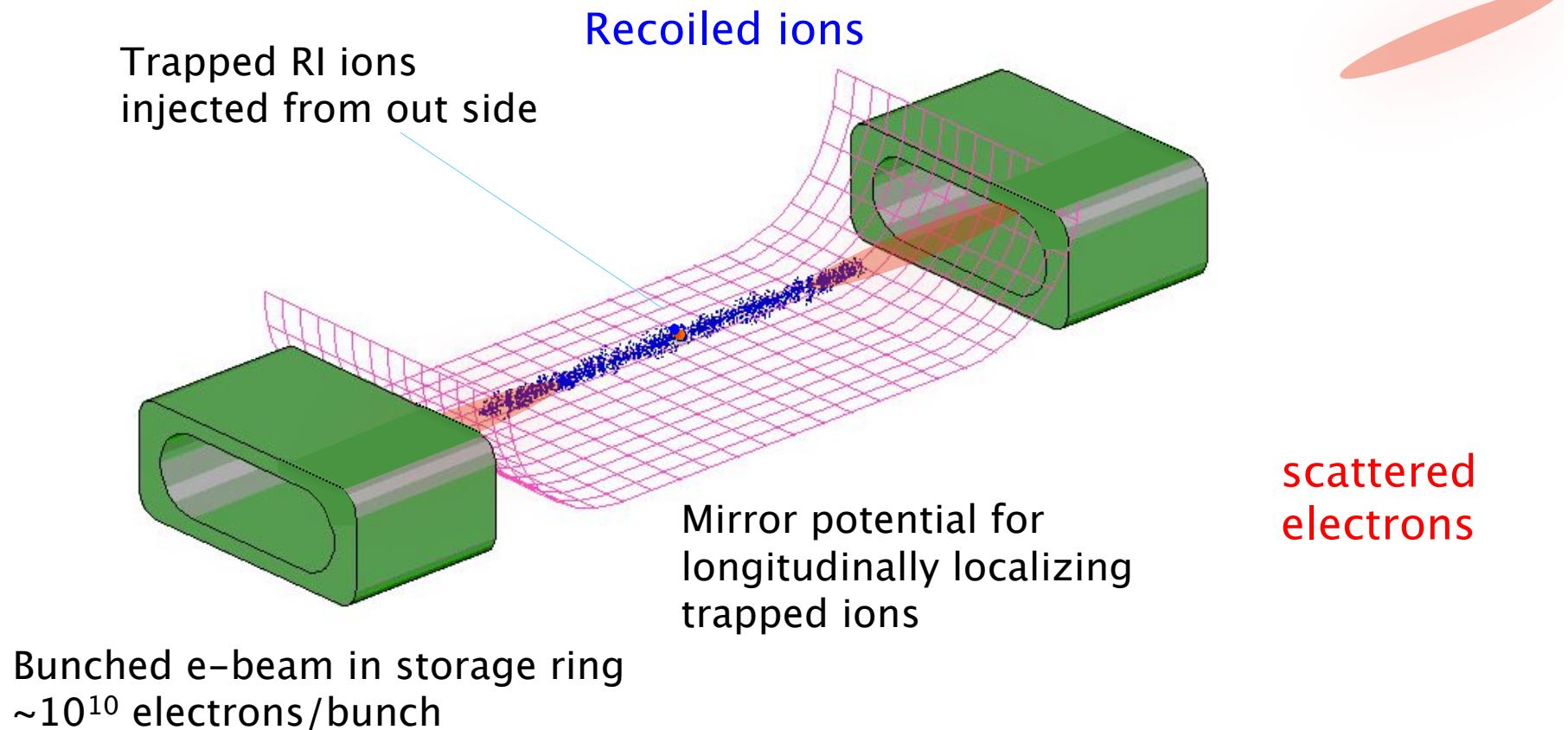
Operation points



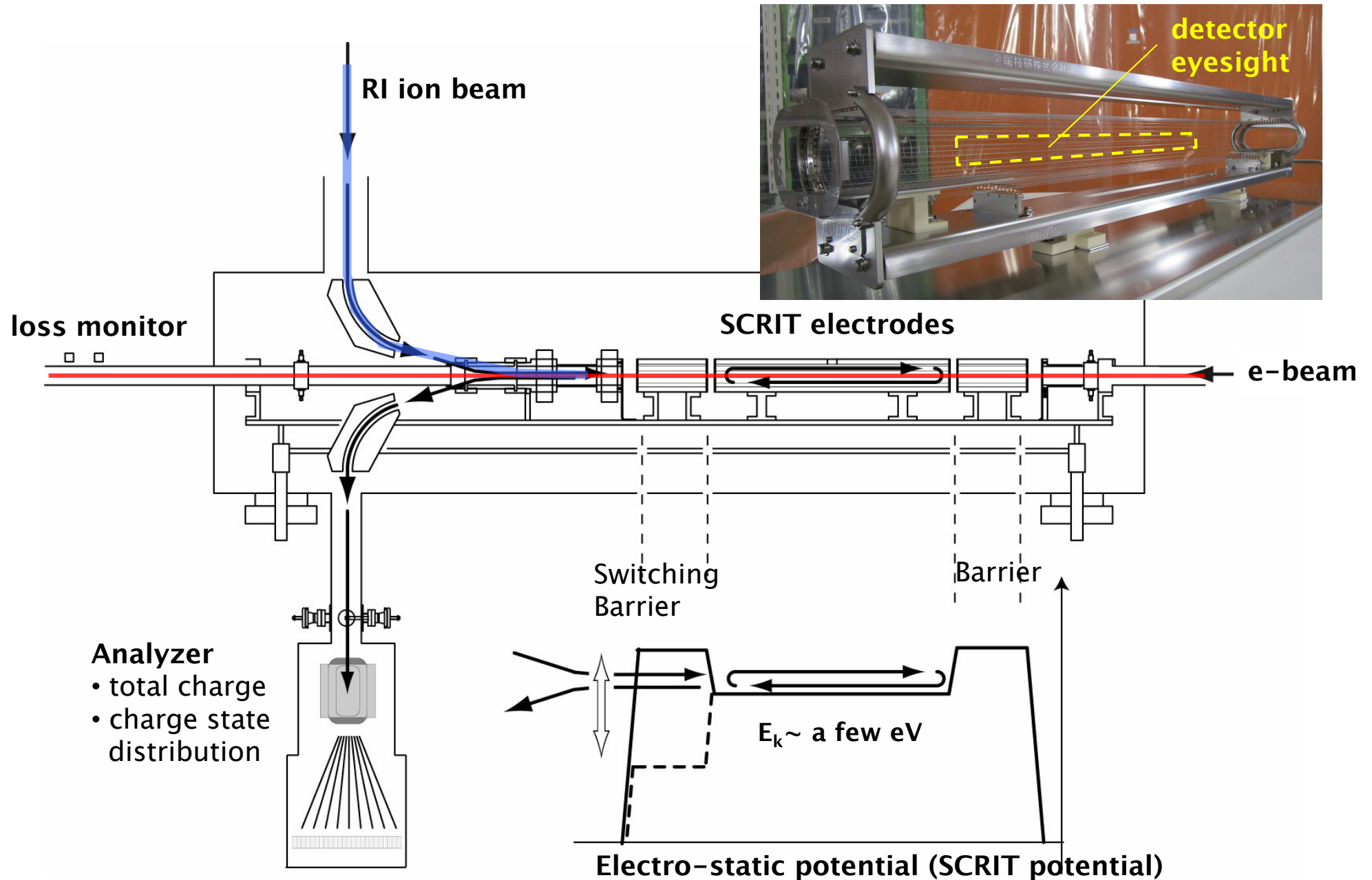
SCRIT (Self-Confining RI Ion Target)

SCRIT is internal-target-forming technique in an electron storage ring.

Target ions are confined in the beam orbit by periodic focusing force.



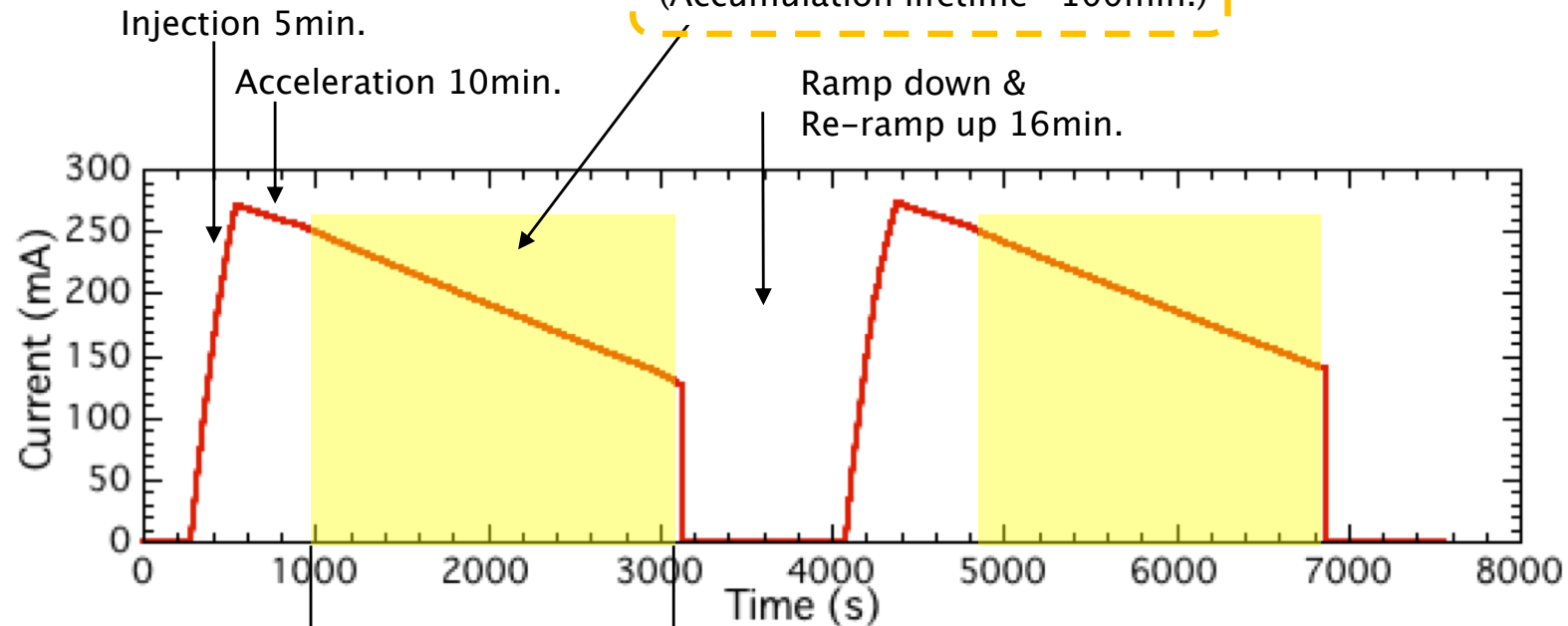
The SCRIT device



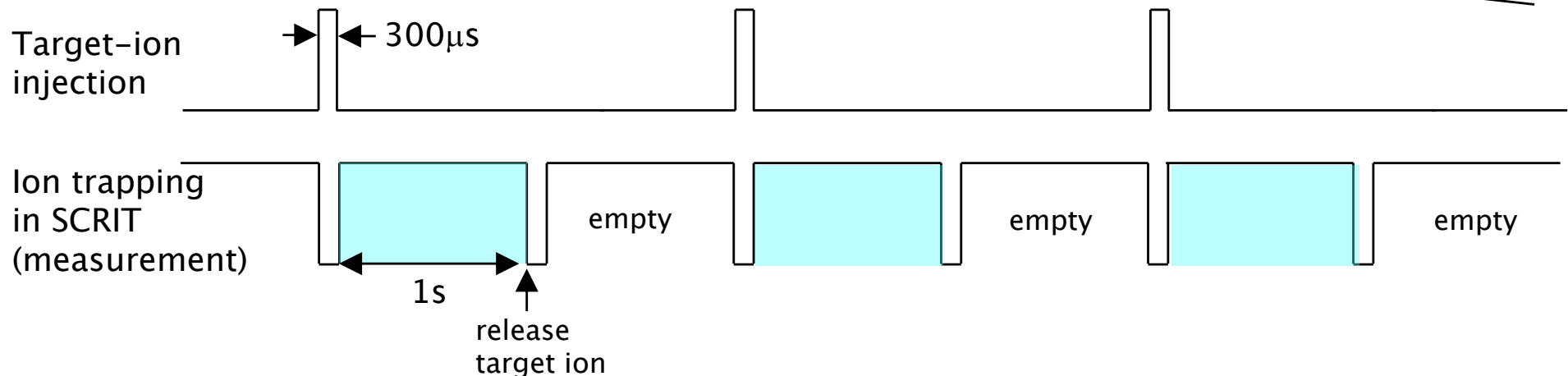
Time sequence of the SCRIT system operation

Total duty factor ~0.25

SR2 operation

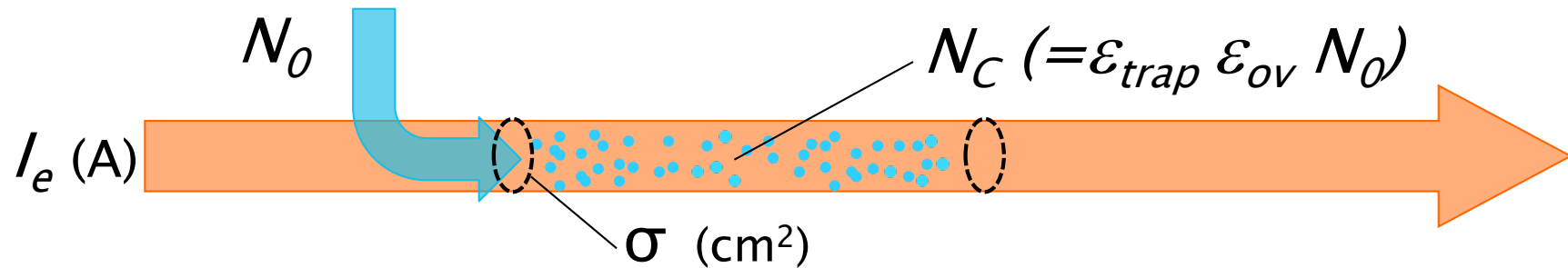


SCRIT operation



Luminosity and its limit in the SCRIT system

Achievable luminosity



$$L \sim \frac{I_e/e \ N_C}{\sigma} \text{ / (cm}^2\text{s)}$$

Current performance (typical)

$$I_e \sim 220 \text{ mA } (1.3 \times 10^{18} \text{ /s)}$$

$$\sigma \sim 3.5 \text{ mm}^2$$

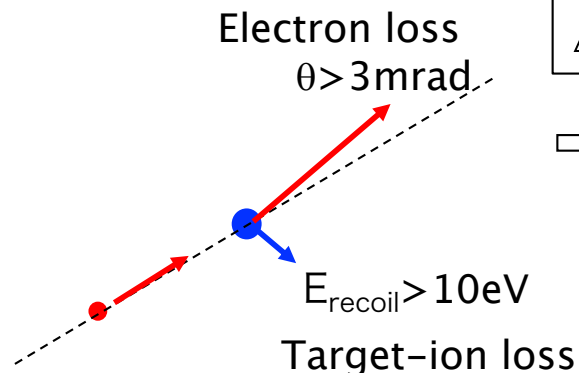
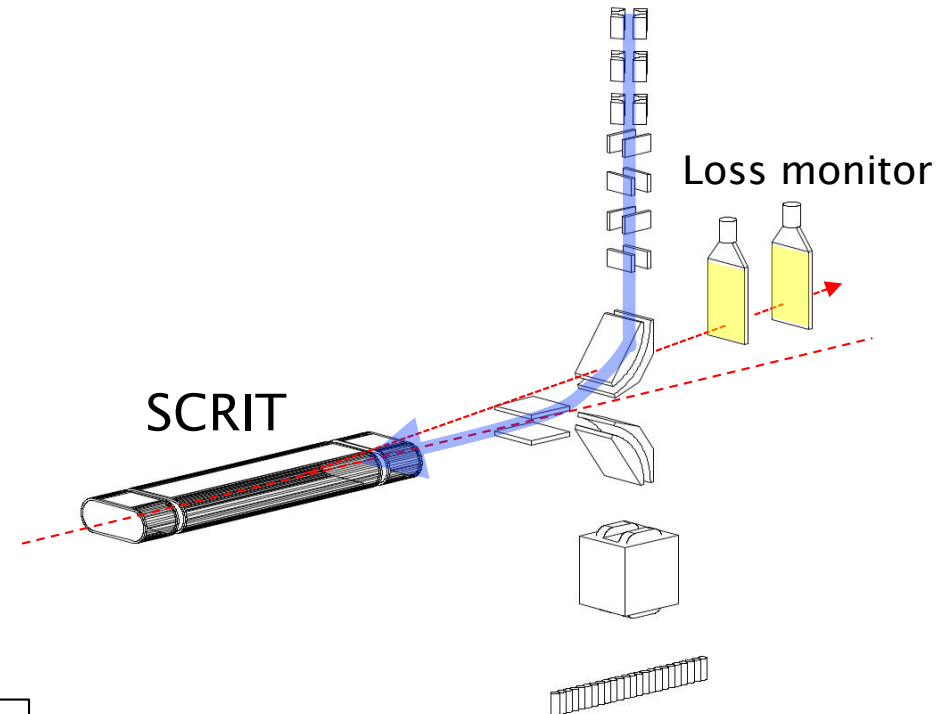
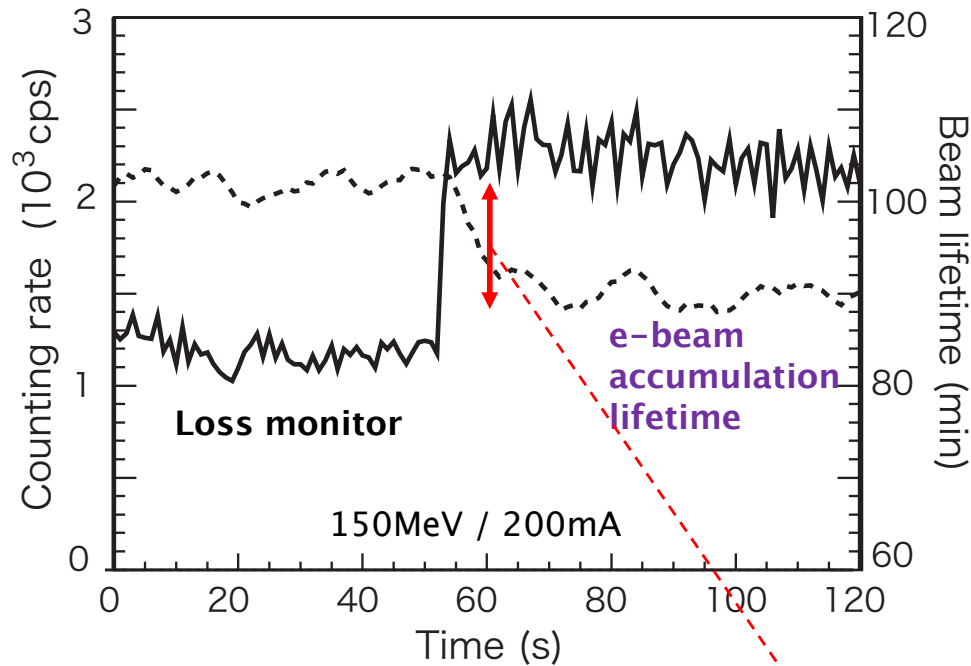
$$N_C \sim 2.6 \times 10^7$$

(Target thickness (N_C/σ) $\sim 7.4 \times 10^8/\text{cm}^2$)

$$\Rightarrow L \sim 10^{27} \text{ / (cm}^2\text{s)}$$

e-beam loss due to collision with target ions

Higher luminosity induces e-beam loss and target-ion loss



$$\Delta\tau = -12 \text{ min.}$$

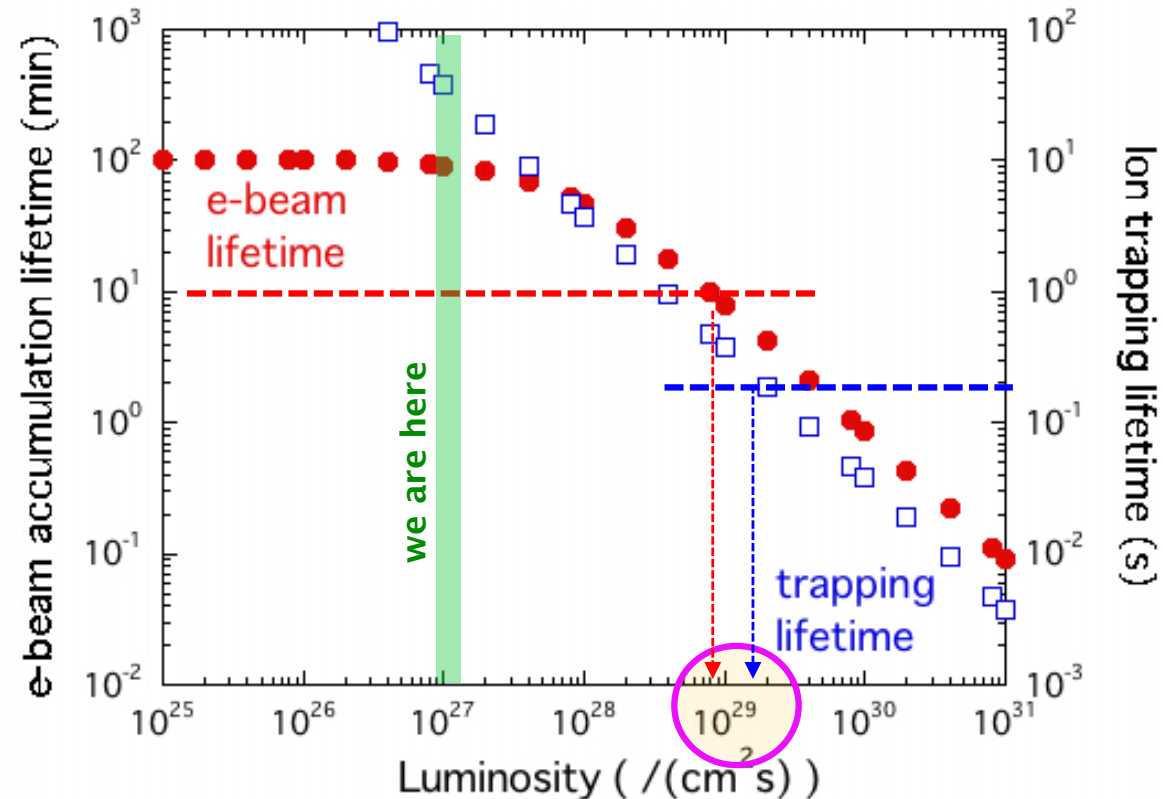


Luminosity $1 \times 10^{27} / (\text{cm}^2 \text{s})$

Electron loss rate due to target ions $2 \times 10^6 / \text{s}$

Target-ion loss rate due to recoil $3 \times 10^6 / \text{s}$

Luminosity limit estimated from the e-beam loss and target ion loss



Assuming minma:

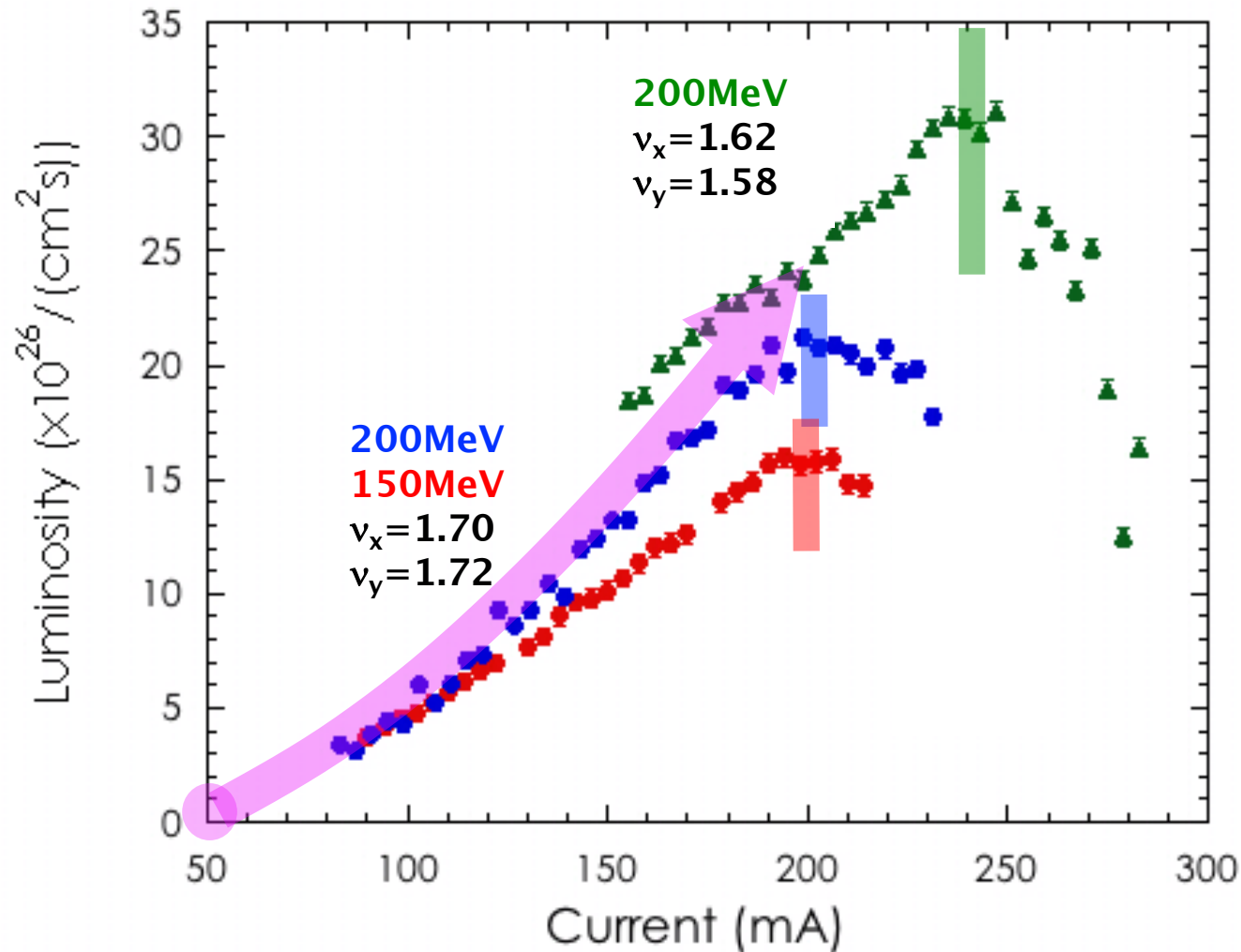
e-beam accumulation lifetime limit = **10 min.**

ion trapping lifetime limit = **200 ms**

Upper limit of luminosity:

➡ **$\sim 10^{29} /(\text{cm}^2\text{s})$**

Achieved luminosity as a function of current



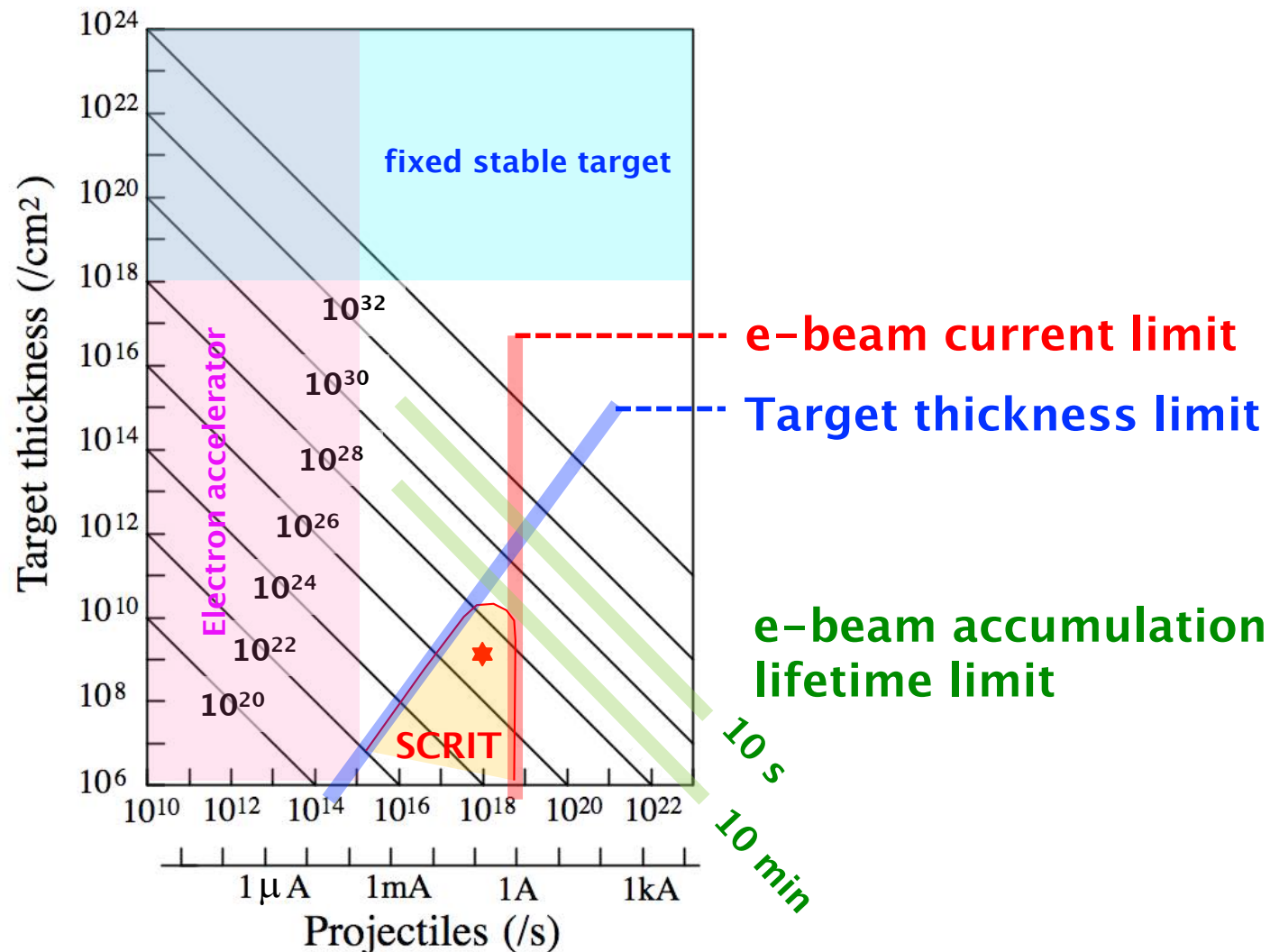
Injection $N_0 = 3 \times 10^8$.

Trapping time 240 ms.

- Ion trapping is started from 50 mA
- Luminosity is increase with current
- Maximum Luminosity $\sim 2 \times 10^{27} / (\text{cm}^2 \text{s})$
- Instability was happen in large current region.
- Luminosity at 200 MeV is lager than that at 150 MeV, because of smaller beam size.

Short summary of luminosity at SCRIT

(with perfectly stable e-beam)



Properties of the target-ion trapping

Trapping efficiency $\varepsilon_{\text{trap}}$ and overlap efficiency ε_{ov}

Injected ions may **wrap around** electron beam axis due to **strong focusing force**.

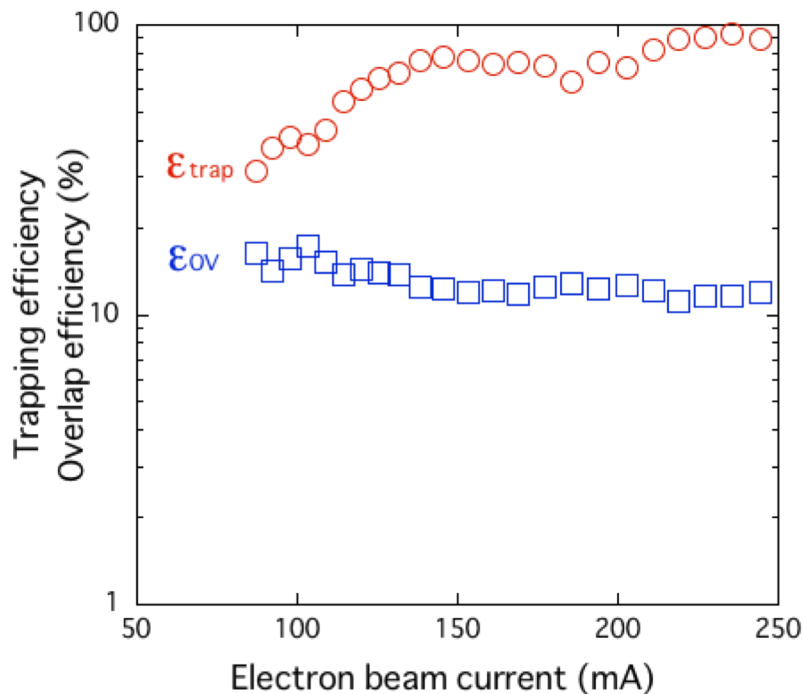
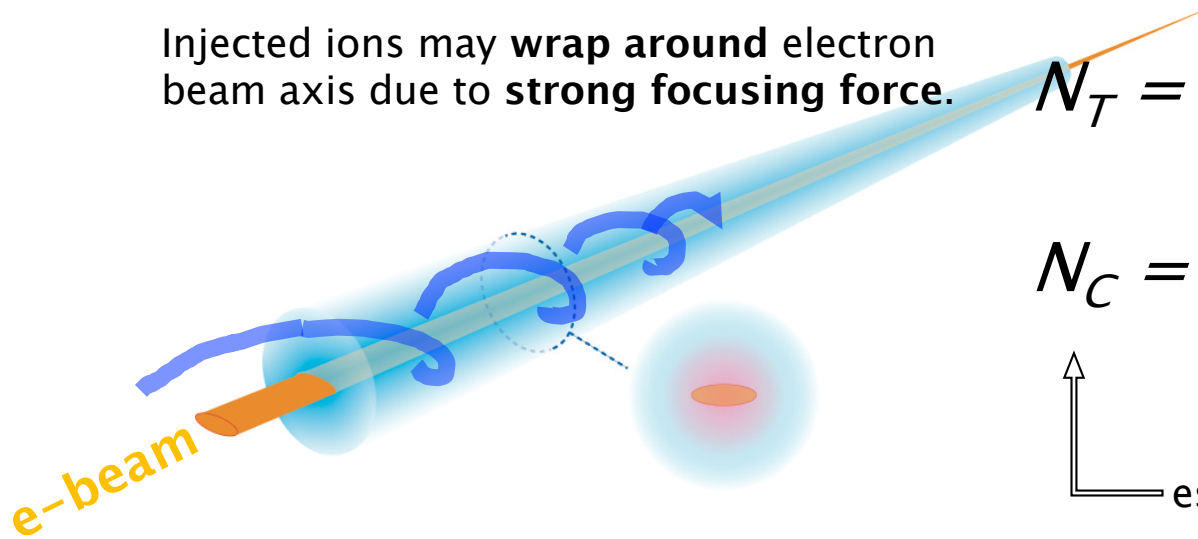
$$N_T = \varepsilon_{trap} \underline{N_0}$$

measurable

$$N_C = \varepsilon_{ov} \underline{N_T} = \varepsilon_{ov} \varepsilon_{trap} N_0$$

= measurable

= estimated from luminosity

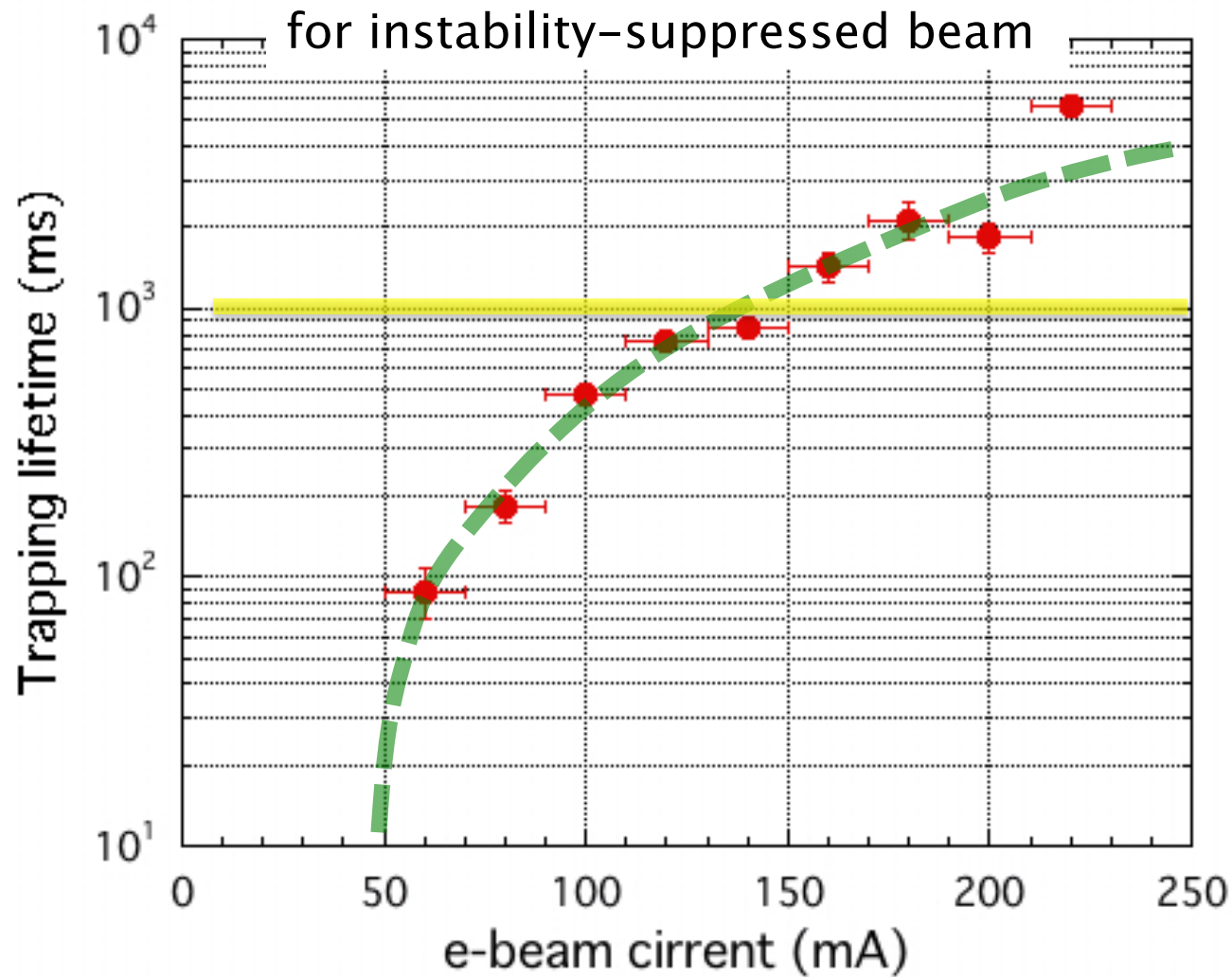


$$\mathcal{E}_{trap} > 90 \%$$

$$\varepsilon_{OV} \sim 13 \%$$

~10 % of injected target ions
participate collision

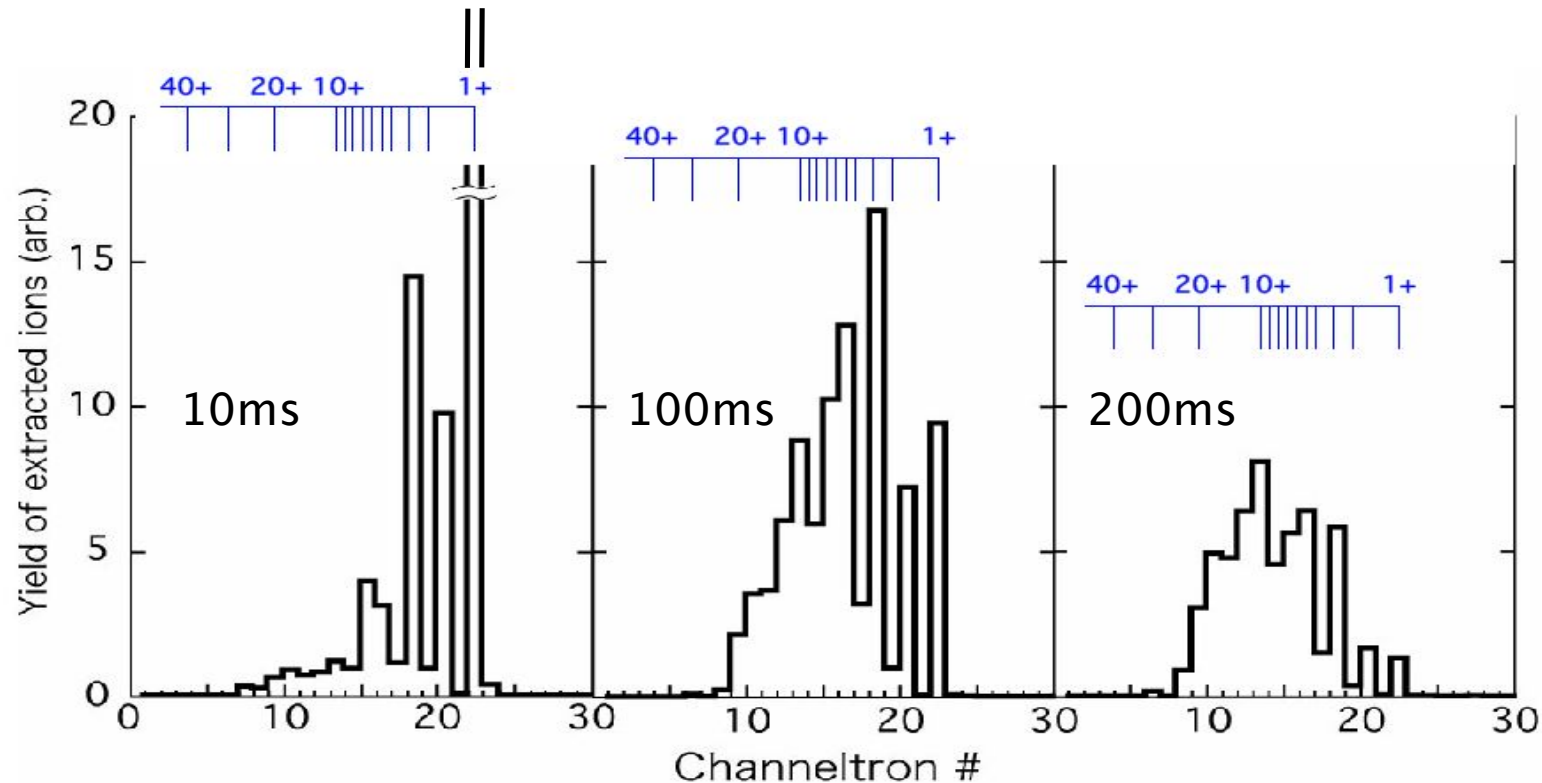
Current dependence of trapping lifetime



Necessary lifetime is
~1s for practical use

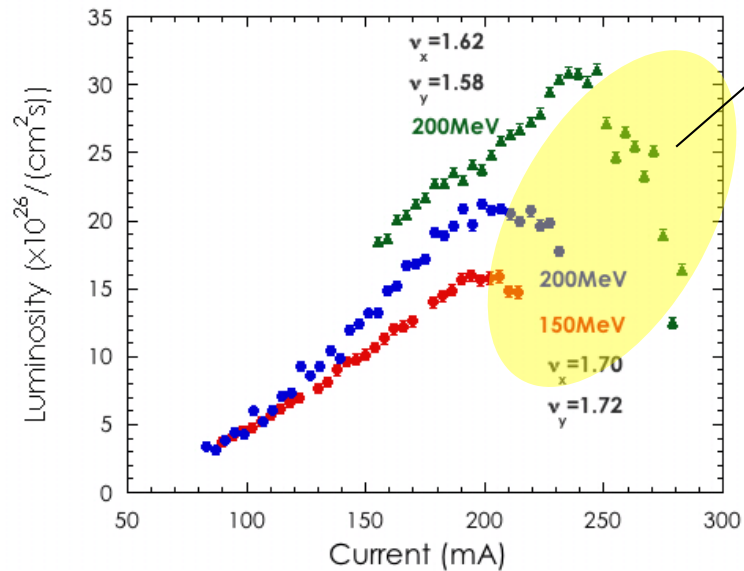
Prerequisite for e-beam
 $I_e > 150mA$
without instability

Temporal evolution of charge states of target ions



- Maximum charge state is $\sim 20^+$, and higher charge states ($>20^+$) do not exist in the SCRIT.
 - Dropout of higher charge state ions
- Rapid increase of a total charge (target ions + residual gas ions)
 - Space charge effect (Neutralization limit : $\sim 10^9$ charges)

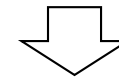
Electron beam instability



What happen in this region

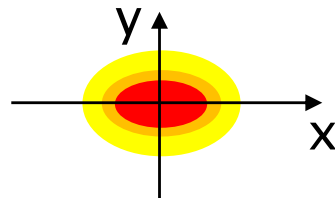
Microwave instability
Coupled bunch instability
HOM excited in cavity
Intra-beam scattering
etc.

coupled to
Synchrotron oscillation
Betatron oscillation

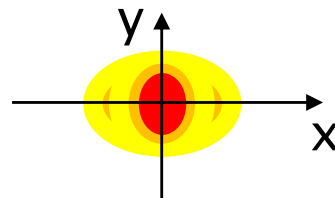


Induced multi-pole coherent motion

Dipole oscillation

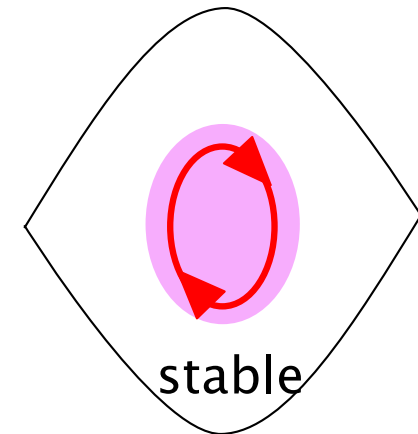
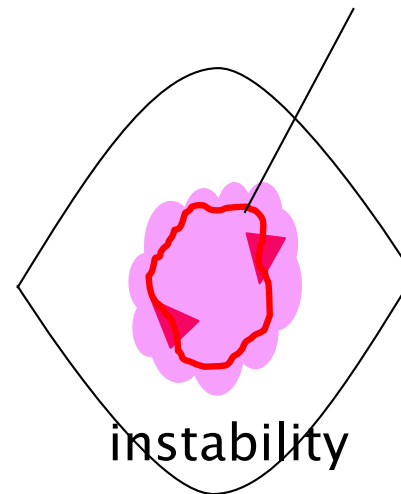


Quadrupole oscillation



⋮
⋮
⋮

higher multi-modes



Beam motion in longitudinal phase space

Influences of e-beam oscillation and space charge on trapping lifetime

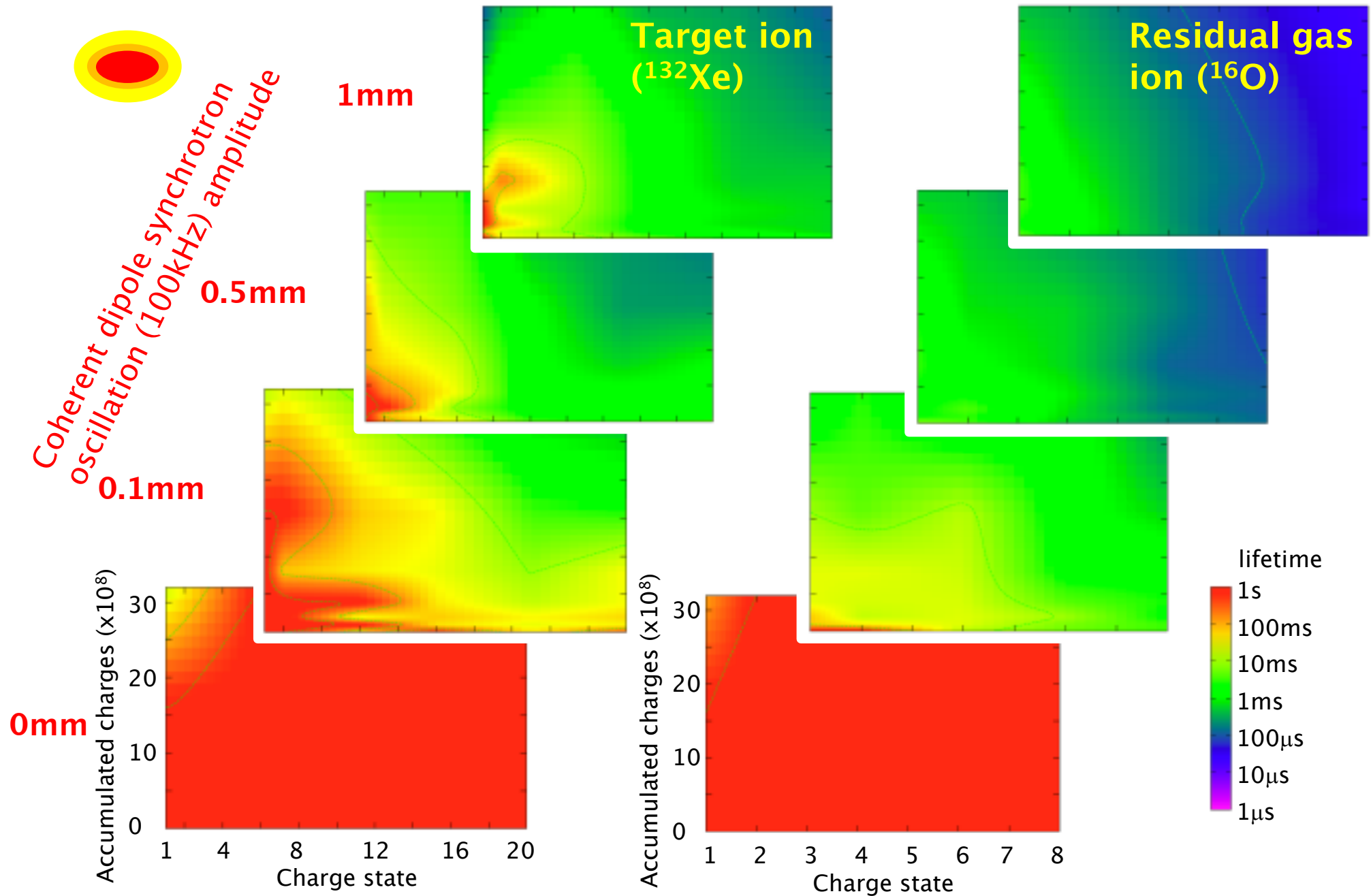


Image of ion trapping with/without e-beam instability

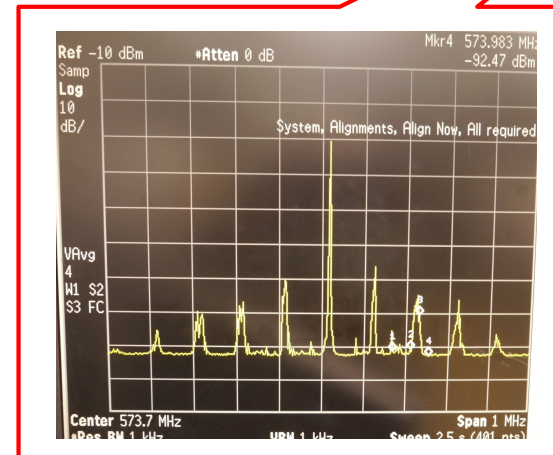
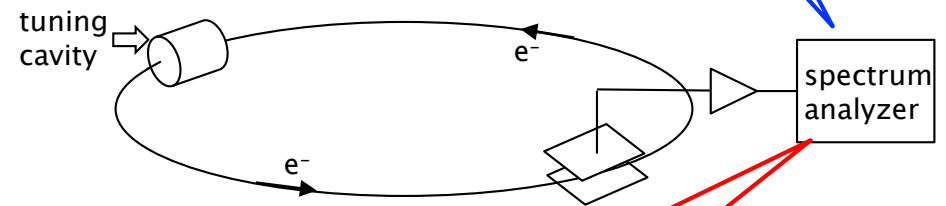
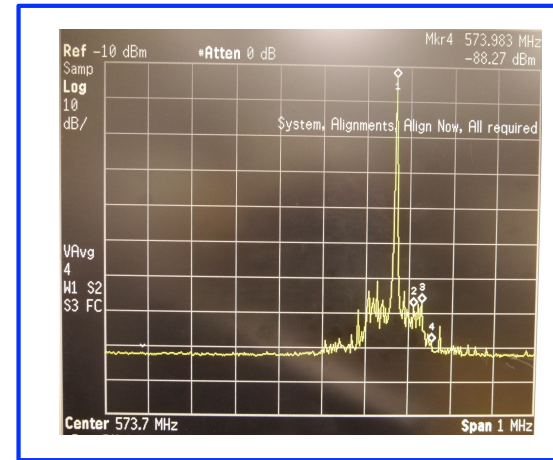
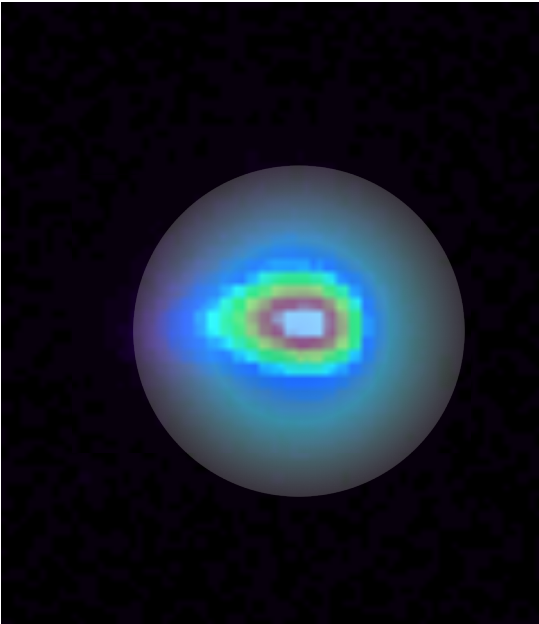
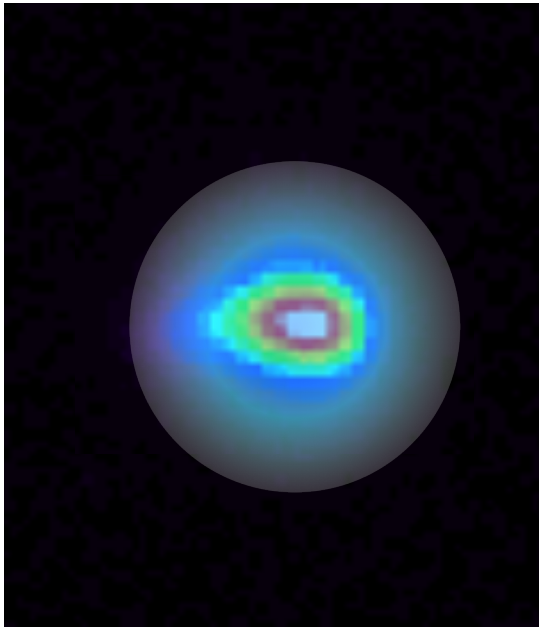
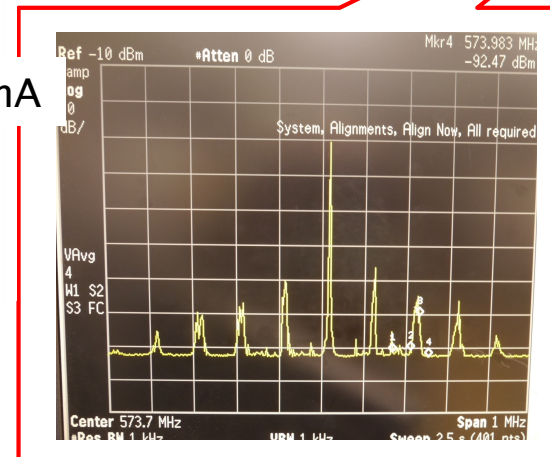
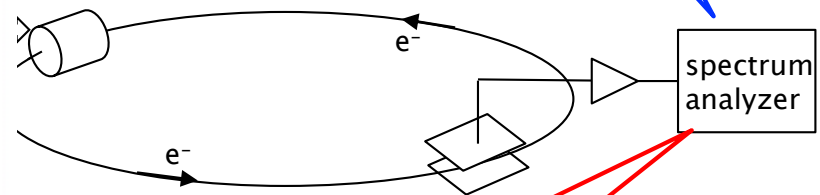
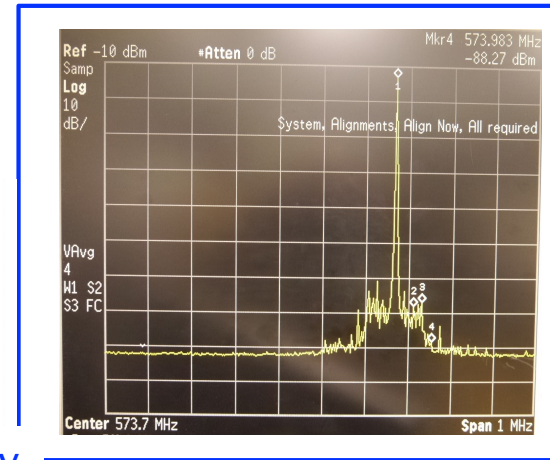
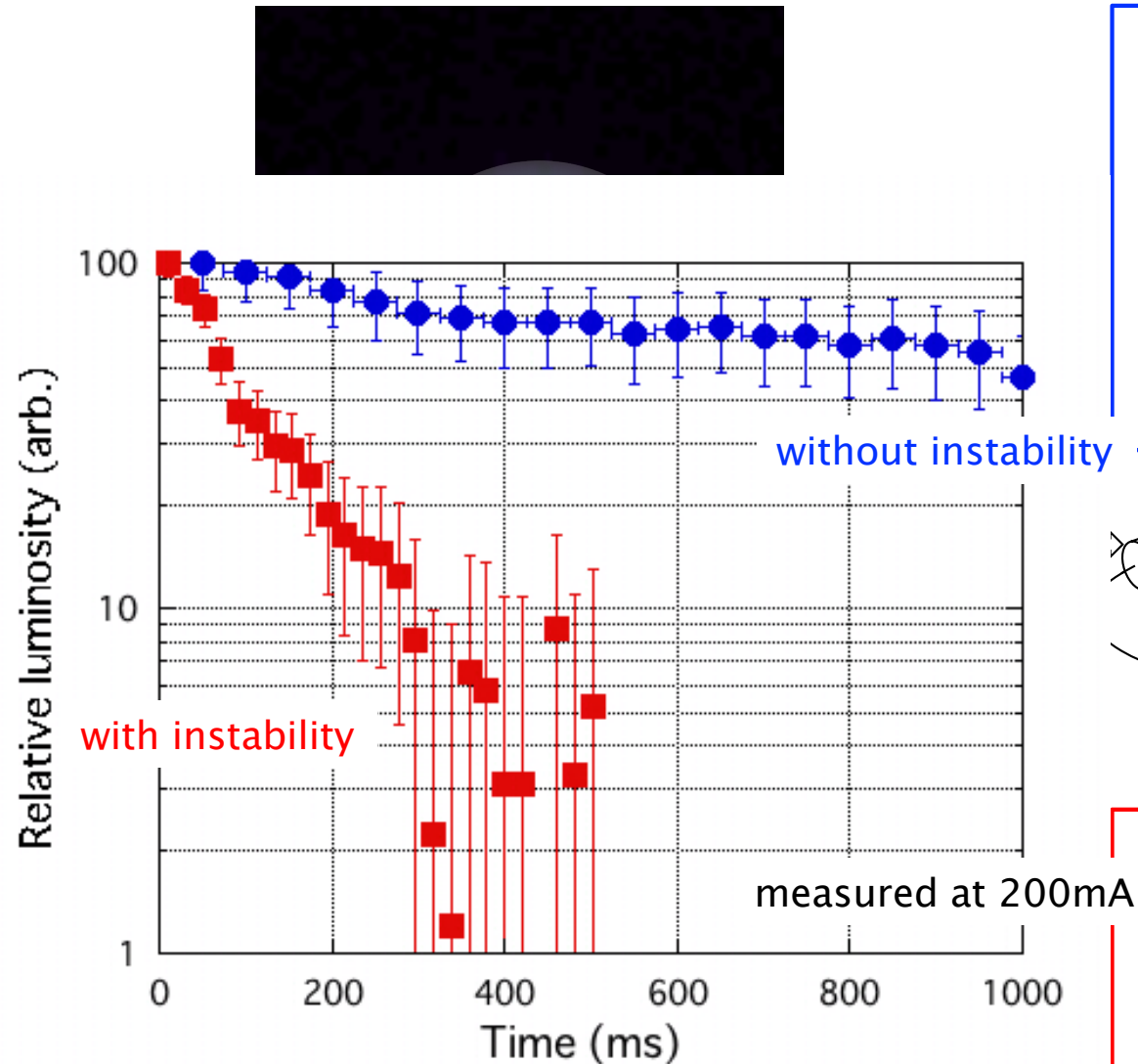
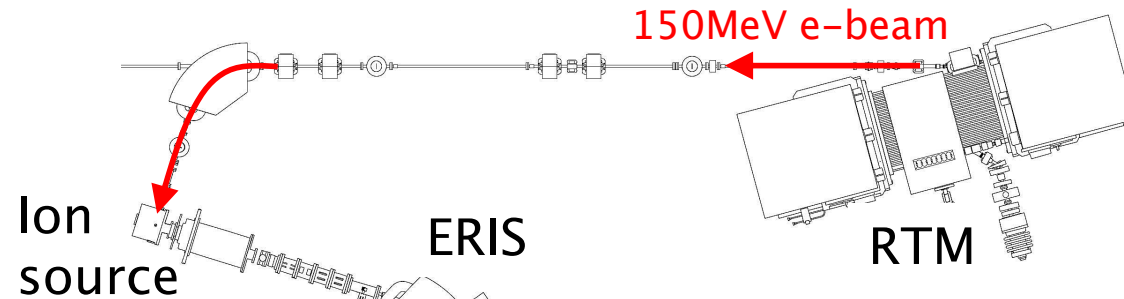


Image of ion trapping with/without e-beam instability



Preparation of target RI ions

ERIS (Electron-beam-driven RI separator for SCRIT)



Performances

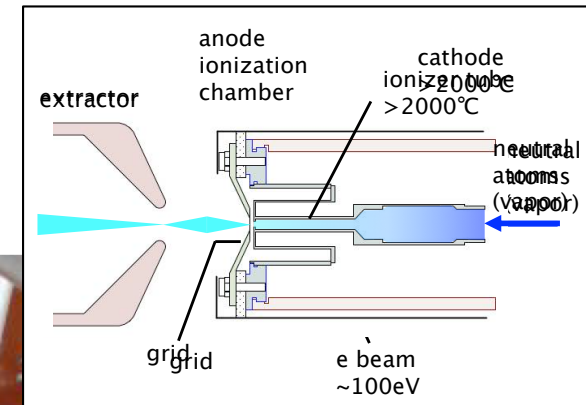
mass resolution $M/\Delta M$ 1660

overall efficiency

21 % (record values for Xe in FEBIAD)

>99 % (Cs in SI)

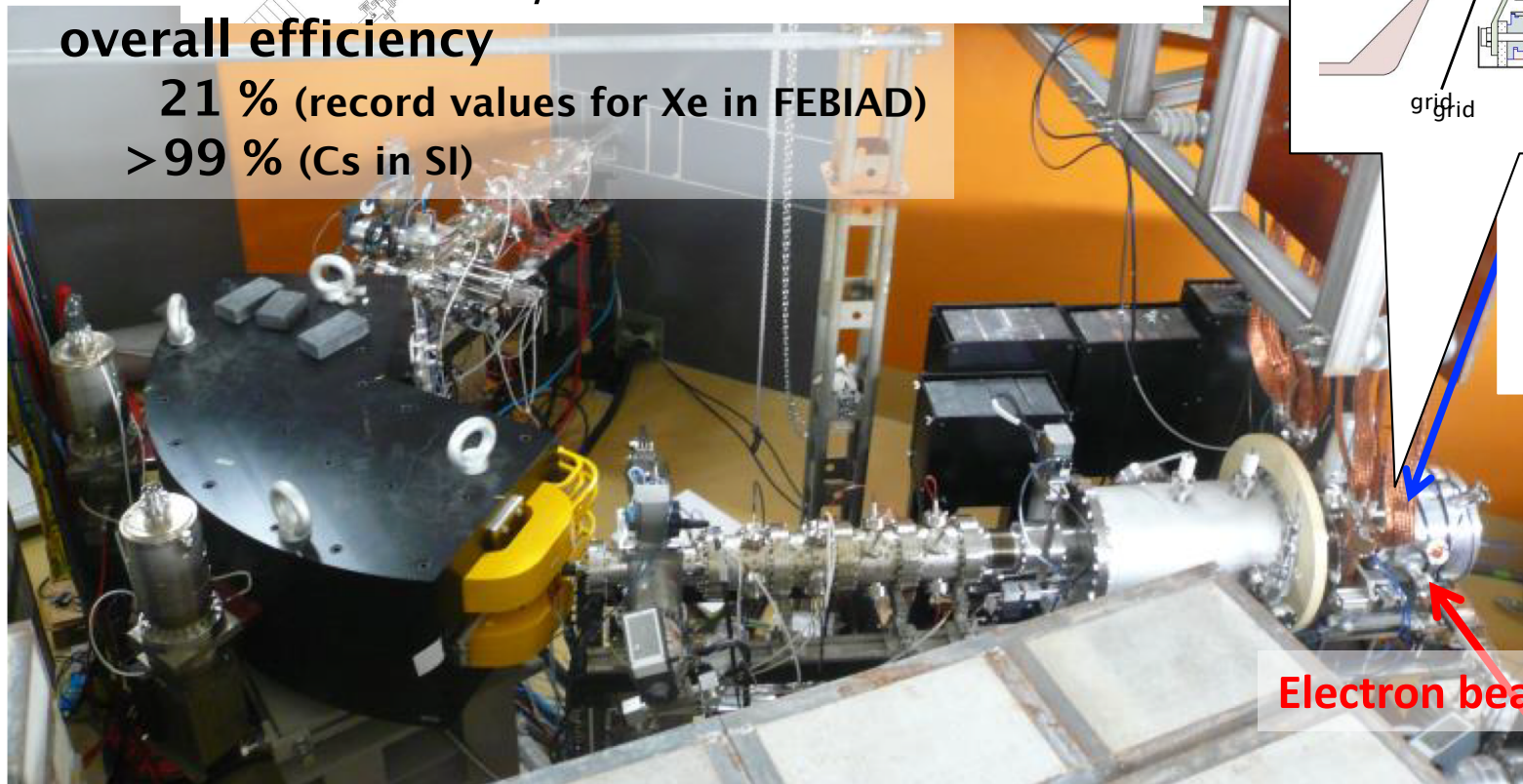
FEBIAD or SI ion source



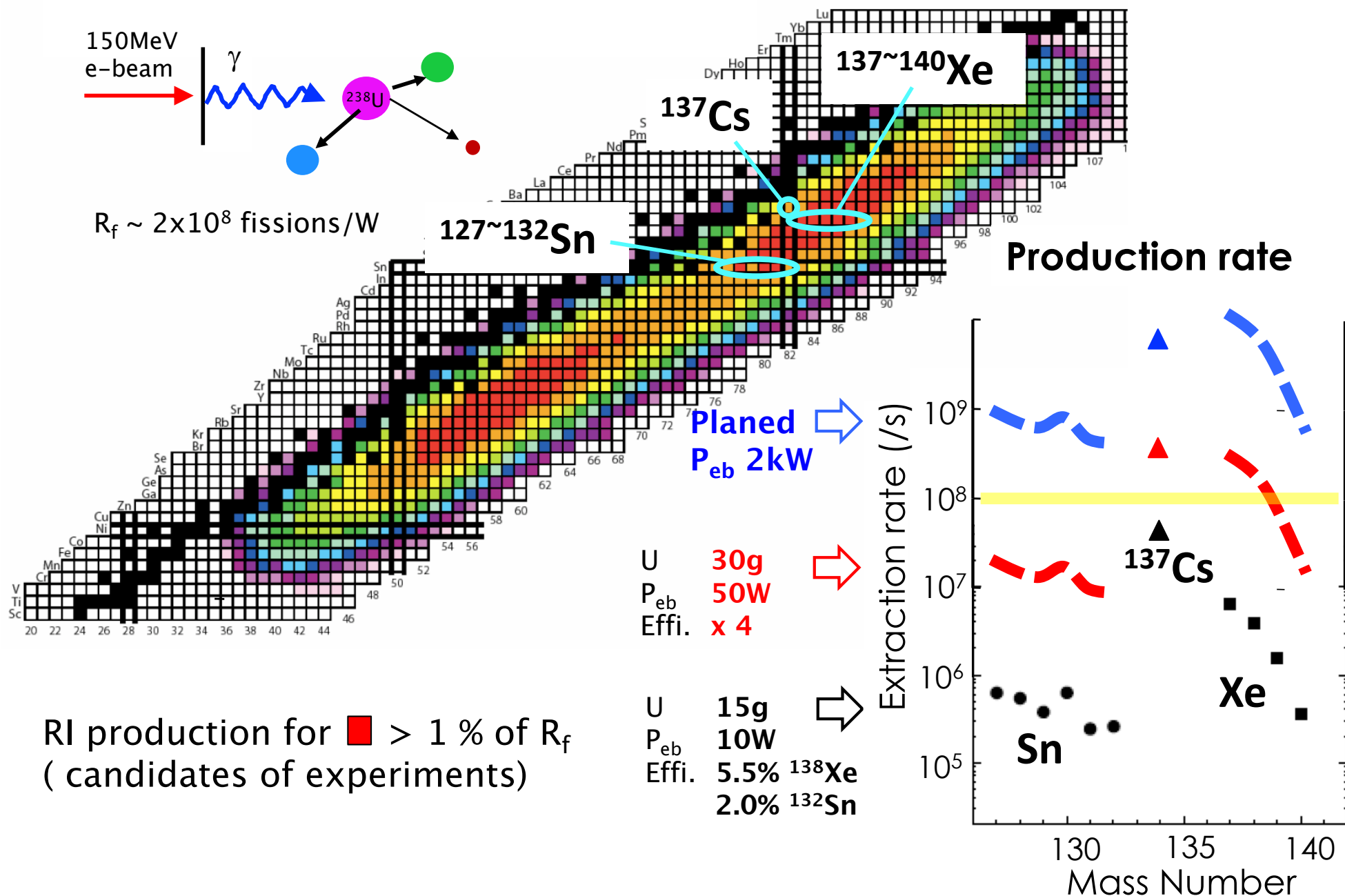
UCx target



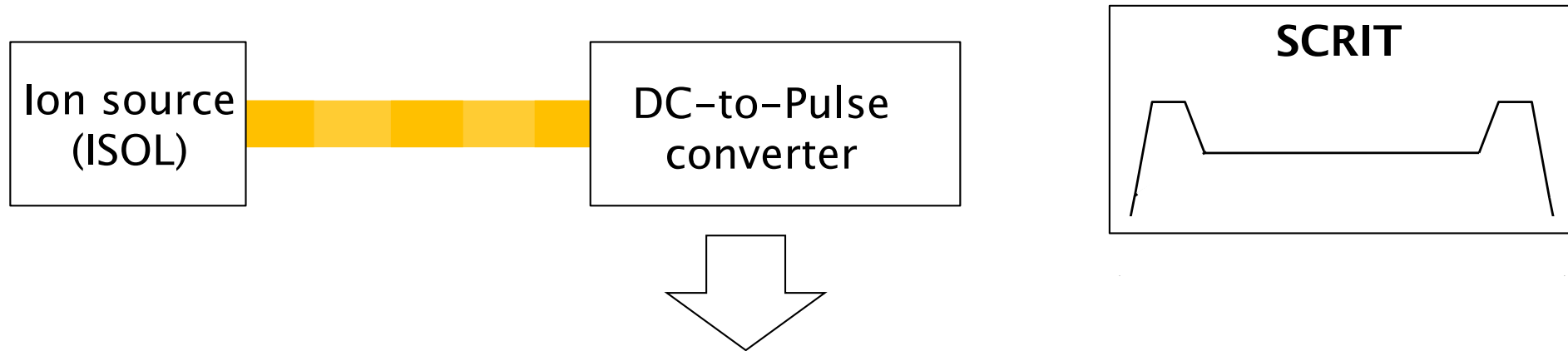
2000 °C



Unstable nuclei produced by photo-fission of ^{238}U



DC-to-Pulse conversion for injecting ions into SCRIT

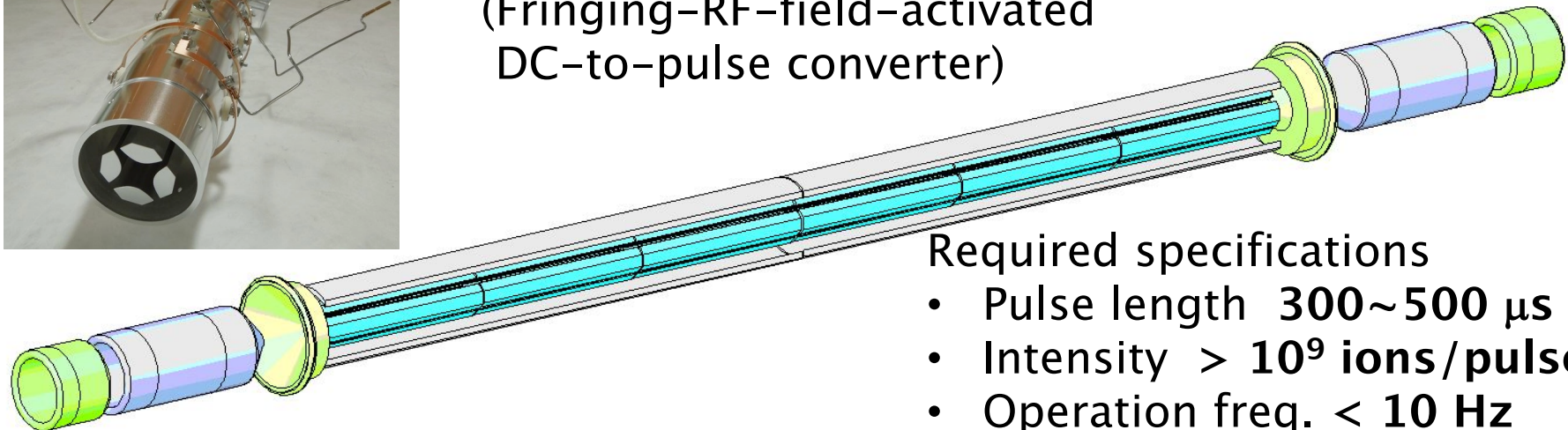


RFQ linear trap device



FRAC

(Fringing-RF-field-activated
DC-to-pulse converter)

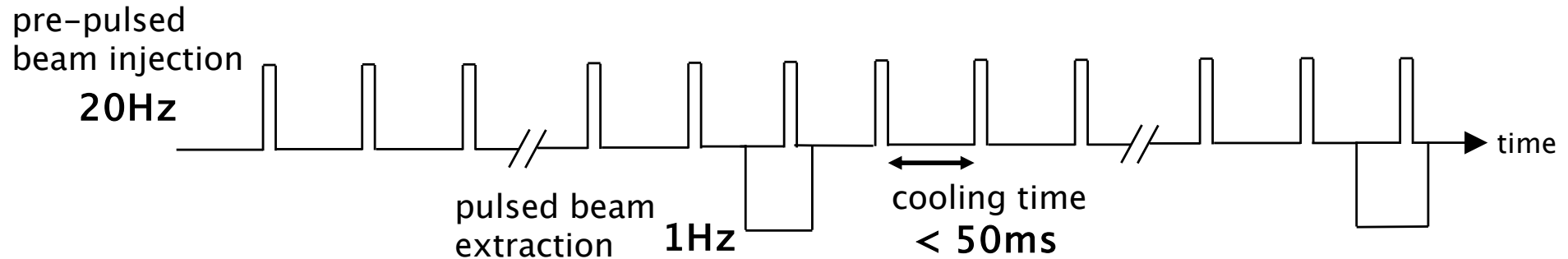


Required specifications

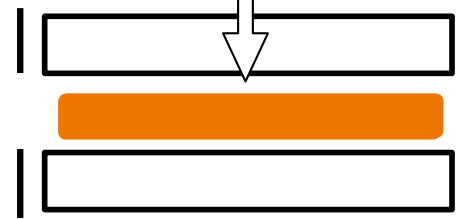
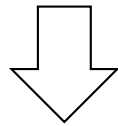
- Pulse length 300~500 μs
- Intensity $> 10^9$ ions/pulse
- Operation freq. < 10 Hz
- Conversion eff. $\sim 100\%$

Two-step pulsing for higher conversion efficiency

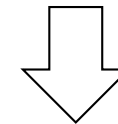
Grid pre-pulsing at IS + Stacking and Cooling in FRAC



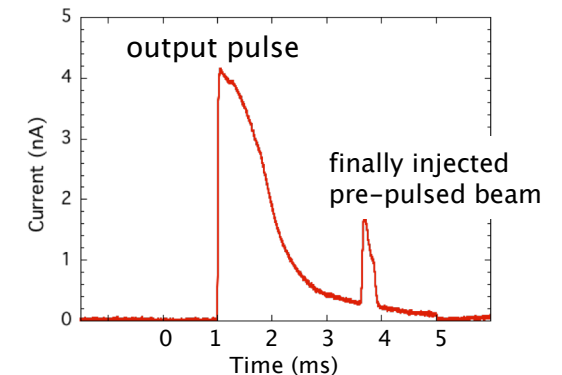
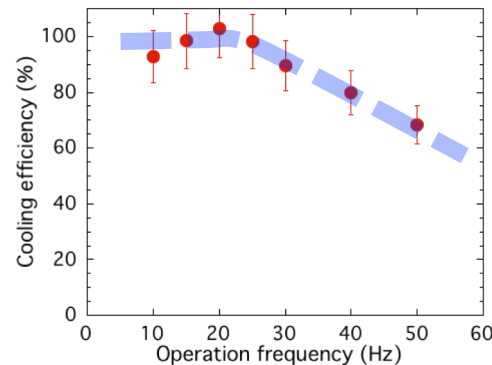
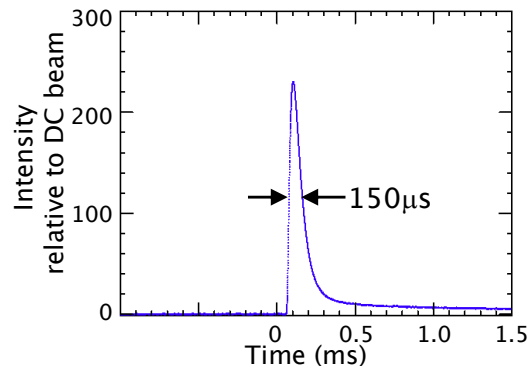
Ion source
with grid



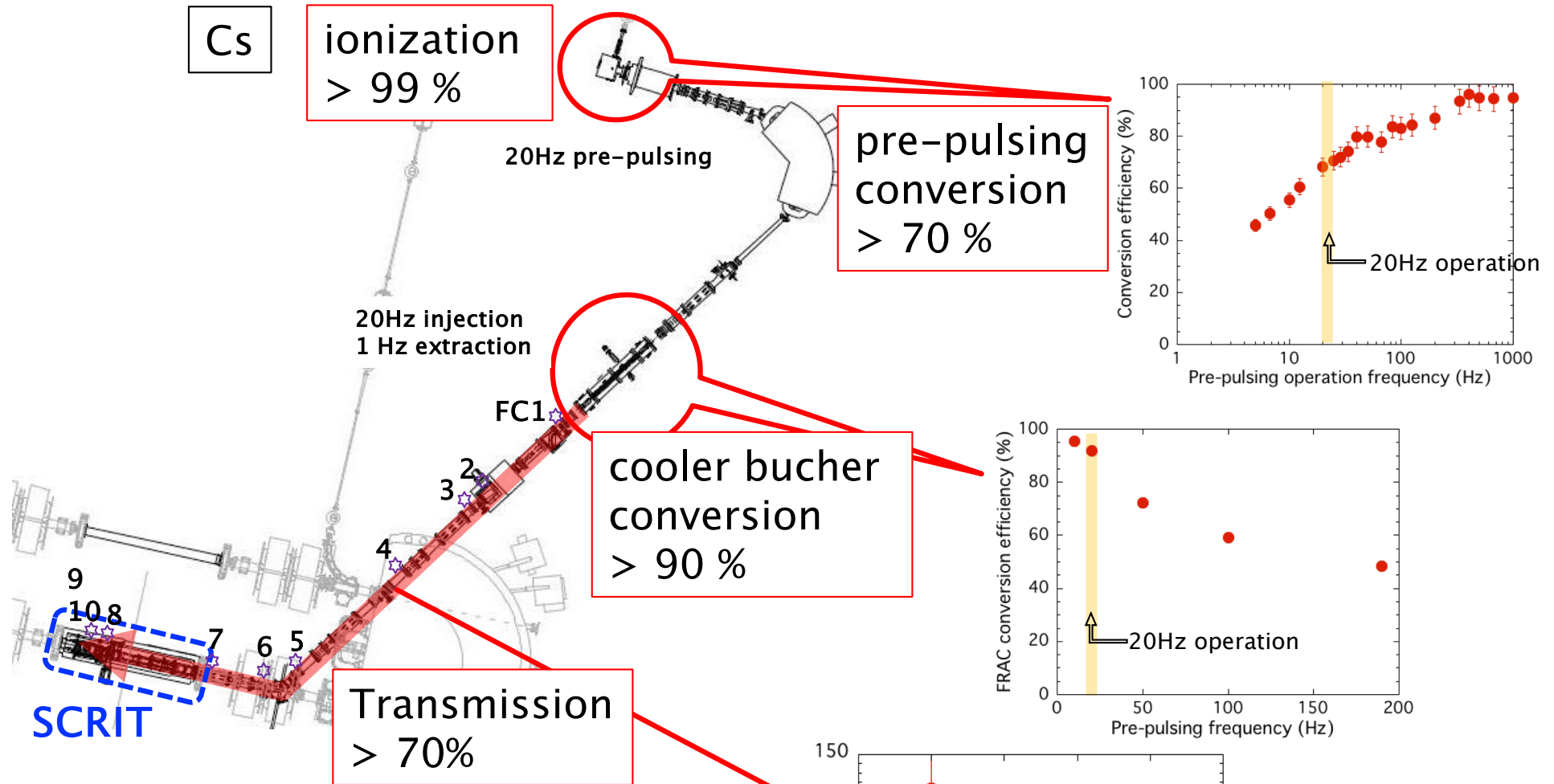
FRAC: Cooler Buncher



Cs



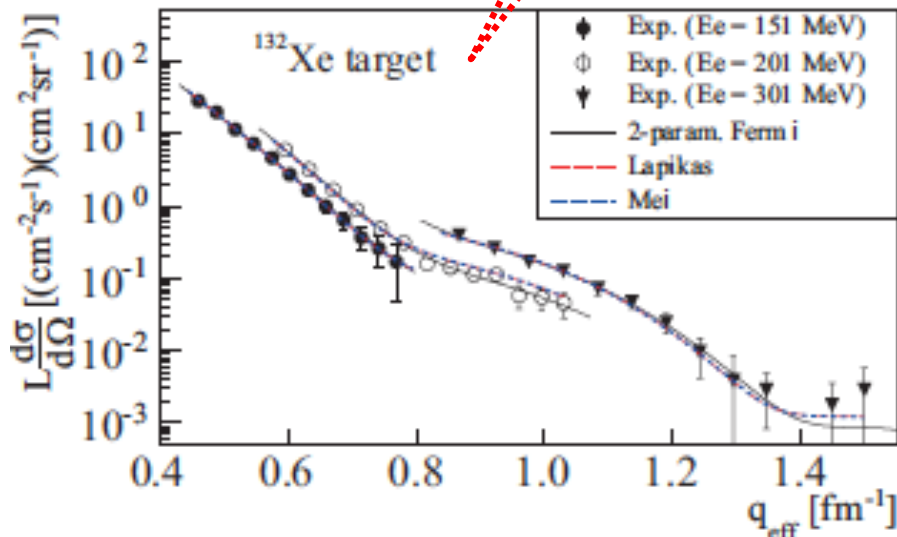
Recent improvement in overall efficiency for target ion injection



$$\frac{(\text{Injected ions into SCRIT})}{(\text{Extracted ions from ERIS})} \sim 50 \%$$

Overall efficiency for target ion injection

	at ^{132}Xe experiment	recent improvements
Injection efficiency	$< 1\%$	$\sim 50\%$
Required ERIS intensity for $L \sim 10^{27}/(\text{cm}^2\text{s})$	a few nA ($\sim 2 \times 10^{10}$ ions/s)	~ 30 pA ($\sim 2 \times 10^8$ ions/s)



Tsukada et al., PRL, 118, 262501 (2017)

The first unstable ^{137}Cs experiment

RTM 10W $\Rightarrow$ 50~100W

of U fissions 2×10^{10} /s

production ^{137}Cs 4×10^8 /s

possible to reach $L \sim 10^{27} /(\text{cm}^2\text{s})$

Summary

1. The SCRIT facility has been constructed and an electron scattering has become one of ISOL experiments
2. Upper limit of achievable luminosity in our SCRIT system is $\sim 10^{29} /(\text{cm}^2\text{s})$, and new technique is required for further luminosity.
3. Electron-beam-instability suppression is the most important issue to get higher and temporally stable luminosity.
4. Improvement of the target-ions transmission from ERIS to SCRIT has been completed, and we will be ready for the first experiment for unstable nuclei.

Thank you for your attention